Appl. No.

10/799,337

Filed

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## AMENDMENTS TO THE CLAIMS

1. (Currently Amended) An apparatus for treating diseased skin with ultraviolet (UV) light, the apparatus comprising:

a source of UV light within the range of 300 and 315 nanometers; and a cooler for cooling the diseased skin to below about 0 °C.

2. (Currently Amended) An apparatus for treating an area of diseased epidermal tissue with ultraviolet UV light, the apparatus comprising:

a source of high intensity ultraviolet light equal to or greater than about 1 minimum erythema dose (MED) in the wavelength range of between about 300 and 315 nanometers having an output for emitting the UV light;

a conduit positioned to receive said ultraviolet light, said conduit having an output end that emits said UV light;

- a delivery device that includes said output end of said conduit; and
- a cooler included in said delivery device <u>configured to cool the skin to to</u> substantially lower than about 34 °C.
- 3. (Original) The apparatus of Claim 2, wherein said delivery device has a localized UV output sufficiently small to illuminate a portion of skin no larger than said area of diseased epidermal tissue.
- 4. (Currently Amended) A method for treating an epidermal region comprising diseased tissue, the method comprising:

cooling the diseased tissue to below about 5 °C and exposing the diseased tissue in said epidermal region to a dosage of ultraviolet light equal to or greater than about 1 minimum erythema dose (MED) in the wavelength range of between about 300 and 315 nanometers.

- 5. (New) The apparatus of Claim 1, wherein the source of UV light comprises an excimer laser.
- 6. (New) The apparatus of Claim 1, wherein the source of UV light has central operating wavelength at about 308 nm.
- 7. (New) The apparatus of Claim 1, wherein the cooler comprises jets configured to spray the skin with a cool liquid, gas, or air.

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8. (New) The apparatus of Claim 1, wherein the cooler comprises a chilled UV transparent substrate.

- 9. (New) The apparatus of Claim 8, wherein the cooler further comprises a thermoelectric cooler.
- 10. (New) The apparatus of Claim 1, wherein a cooler is configured to cool the diseased skin to below about -5 °C.
- 11. (New) The apparatus of Claim 2, wherein the source of high intensity ultraviolet light comprises an excimer laser.
- 12. (New) The apparatus of Claim 2, wherein the source of high intensity ultraviolet light has a central output wavelength of about 308 nm.
- 13. (New) The apparatus of Claim 2, wherein the cooler comprises a channel configured to spray the skin with a cool liquid, gas, or air through an opening therein.
- 14. (New) The apparatus of Claim 2, wherein the cooler comprises a chilled UV transparent substrate.
- 15. (New) The apparatus of Claim 2, wherein a cooler is configured to cool the diseased skin to below about -5 °C.
- 16. (New) The method of Claim 4, wherein the epidermal region exposed to ultraviolet has an area between about 1 cm<sup>2</sup> and about 4 cm<sup>2</sup>.
- 17. (New) The method of Claim 4, wherein cooling comprises spraying the skin with a cool liquid, gas, or air.
- 18. (New) The method of Claim 4, wherein cooling comprise contacting the diseased tissue with a chilled surface.
- 19. (New) The method of Claim 4, wherein the diseased tissue is cooled to below about 0 °C.
- 20. (New) The method of Claim 4, wherein the diseased tissue is cooled to below about -5 °C.